

Special Issue

Photosensitive Materials and Their Applications

Message from the Guest Editors

Photosensitive materials represent a huge variety of materials of both inorganic and organic nature that are capable of changing their structural (chemical and/or physical) properties under light exposure. They are applied to many fields dealing with light exploitation, such as imaging, solar technology, holography, optical data storage, optical sensing, photonics, optical structuring of surface, etc. Depending on their potential application, photosensitive materials can be developed as coatings, films, nanostructures, surface structures, liquid crystal layers and others. This Special Issue focuses on photosensitive materials and their applications. The topics of interest include but are not limited to: Photosensitive materials for optoelectronics; Photosensitive materials for optical patterning of surfaces;

Holographic recording materials;

Holographic optical elements;

Functionalised photosensitive materials for sensing applications;

Photosensitive hybrid nanostructured materials for sunlight capture;

Photosensitive nanocomposite materials;

Materials for two-photon polymerisation lithography;

Photosensitive materials for application in photonic devices.

Guest Editors

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Deadline for manuscript submissions

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About the Journal

Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal Applied Sciences has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

Editor-in-Chief

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